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PATENT

AF/1753  
JPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: John Commander, et al. Art Unit: 1753  
Serial No.: 10/091,106  
Filed: March 5, 2002  
Confirmation No.: 5919  
For: DEFECT REDUCTION IN ELECTRODEPOSITED  
COPPER FOR SEMICONDUCTOR APPLICATIONS  
Examiner: Edna Wong

July 27, 2005

**AMENDMENT E AFTER FINAL**

TO THE COMMISSIONER FOR PATENTS,

SIR/MADAM:

This responds to the Office action mailed May 27, 2005.

Please enter the following amendments and consider the following remarks.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.

Conclusion begins on page 7 of this paper.

Okuy to enter. 02/8/5/05